

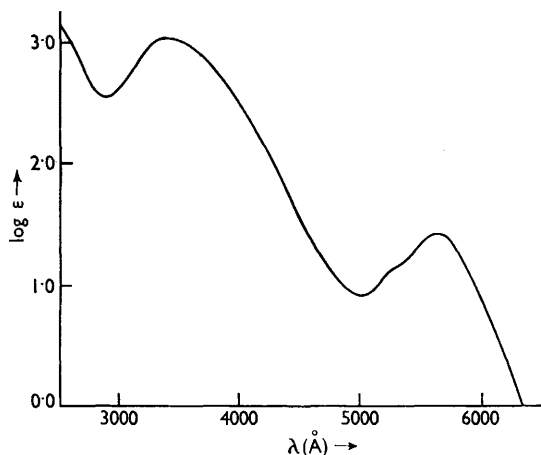
## The Electronic Spectrum and Photolysis of S-Nitrosotoluene- $\alpha$ -thiol

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S-NITROSOTOLUENE- $\alpha$ -THIOL,  $C_6H_5 \cdot CH_2 \cdot SNO$ , was prepared by the method reported by Saville.<sup>1</sup> The compound in dilute ( $4 \times 10^{-2}M$ ) hexane solution was found to be thermally stable at 25° over a period of weeks. 3650Å-radiation caused the decomposition of the compound, the only products being nitric oxide and dibenzyl disulphide.

The electronic spectrum of S-nitrosotoluene- $\alpha$ -thiol in hexane solution was measured and is shown in the Figure. The absorption at  $\lambda_{max} =$

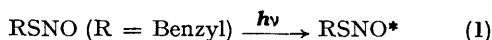


The electronic spectrum of S-nitrosotoluene- $\alpha$ -thiol in hexane solution

5600 Å ( $\epsilon$ , 26) for which the oscillator strength,  $f$ , is  $2 \times 10^{-4}$ , may be assigned to an  $n_N \rightarrow \pi^*$  transition. A similar assignment has been made<sup>2</sup> for the absorption at 5988 Å of S-nitroso-2-methylpropane-2-thiol. The shoulder at 5300 Å can be attributed to the existence of two rotational isomers of the molecule as have been shown to exist in the analogous alkyl nitrite.<sup>3</sup> The band is not photochemically active.

The absorption at  $\lambda_{max} = 3400$  Å ( $\epsilon$ , 1030) with  $f = 2.7 \times 10^{-2}$ , is responsible for the photo-activity of the molecule. It is assigned to an  $n_O \rightarrow \pi^*$  transition. The  $\pi \rightarrow \pi^*$  transition is in the benzenoid region at 2200 Å ( $\epsilon \sim 10^4$ ).

The result of the irradiation of S-nitrosotoluene- $\alpha$ -thiol at 3650 Å would be the excitation of an electron from the pure  $p$ -lone-pair orbital on the oxygen atom to a  $\pi$ -orbital which would be anti-bonding with respect to the nitrogen and oxygen atoms. The absorption of 3650 Å-radiation causes excitation to the extent of 79 kcal. mole<sup>-1</sup>, this being in excess of the calculated sulphur-nitrogen bond dissociation energy of 52 kcal. mole<sup>-1</sup> and sufficient to cause the fission of this bond. By the homolytic fission of the sulphur-nitrogen bond the orbital on the nitrogen atom containing a single electron can be used, together with the  $p$ -orbital on the oxygen atom which also contains one electron, to form a second  $\pi$ -bond between the nitrogen and oxygen atoms. Thus formed, the nitric oxide would be in its electronic ground state. These processes can be formulated as:



Evidence for thiol radical production is that the monomers acrylonitrile and methyl methacrylate reduce the quantum yield for RSNO disappearance from 0.8 to a limiting value of 0.4 and in doing so become polymerised. These observations are consistent with the mechanism for the photolysis of reactions (1) and (2) followed by:



Thiyl radicals are known to react rapidly with sulphur-sulphur bonds<sup>4</sup> and there seems to be no reason to expect their reaction with sulphur-nitrogen bonds to be very different.

S-Nitroso-derivatives of the following thiols have been prepared and undergo similar photolysis: n-hexanethiol, 2-methylpentane-4-thiol, 2-methylpropanethiol, cyclohex-3-enethiol, 2-methylpentane-2-thiol and 2-methylpropane-2-thiol.

Some support for the argument that the electronic changes occurring subsequently to an  $n_O \rightarrow \pi^*$  transition, which so conveniently result in a thiyl radical and the electronic ground state of nitric oxide, are a major factor in producing

<sup>1</sup> B. Saville, *Analyst*, 1958, **83**, 660.

<sup>2</sup> G. Kreze and U. Uhlich, *Chem. Ber.*, 1959, **92**, 1048.

<sup>3</sup> L. H. Piette and W. A. Anderson, *J. Chem. Phys.*, 1959, **30**, 899.

<sup>4</sup> W. A. Pryor, "Mechanisms of Sulphur Reactions," McGraw-Hill series in Advanced Chemistry, 1962, p. 51.

high quantum yields in these photolyses comes from a study of the photochemistry of the analogous nitrites and *N*-nitroso-compounds. Bamford<sup>5</sup> reports that *N*-nitrosodimethylamine and *N*-nitrosodiethylamine have quantum yields for decomposition at 3650 Å of only 0.01. It is known<sup>6</sup> that 3650 Å-radiation has no effect on *N*-nitrosodibenzylamine. In these cases the radiation would cause  $n_N \rightarrow \pi^*$  transitions<sup>7</sup> and in spite of the fact that there would be ample energy to break the nitrogen–nitrogen bond there would have to be a major electronic rearrangement in

order to produce nitric oxide in its electronic ground state. This limitation also applies to the photolysis of nitrites at 3650 Å and these do involve very low quantum yields, *e.g.* for the photolysis of *t*-butyl nitrite<sup>8</sup>  $\phi = 0.08$ . There are, however, some exceptions in the case of nitrite photolyses, these being those instances where the alkoxy-radical can undergo the Barton reaction<sup>9</sup> effectively or can abstract a hydrogen atom from a solvent molecule.

(Received, May 4th, 1965.)

<sup>5</sup> C. H. Bamford, *J. Chem. Soc.*, 1939, 12.

<sup>6</sup> J. Barrett, L. H. Fitzgibbons, and P. J. N. Young, unpublished observations.

<sup>7</sup> S. F. Mason, *Quart. Rev.*, 1961, 15, 287.

<sup>8</sup> H. W. Thompson and F. S. Dainton, *Trans. Faraday Soc.*, 1937, 33, 1546.

<sup>9</sup> M. Akhtar, *Adv. Photochem.*, 1964, 2, 263.